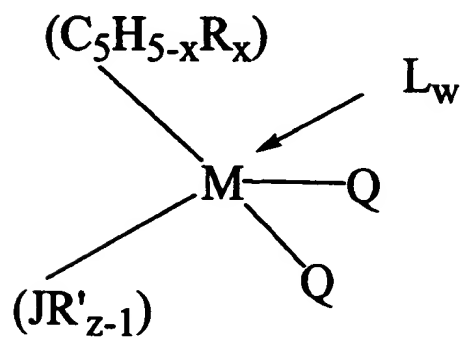


LISTING OF CLAIMS

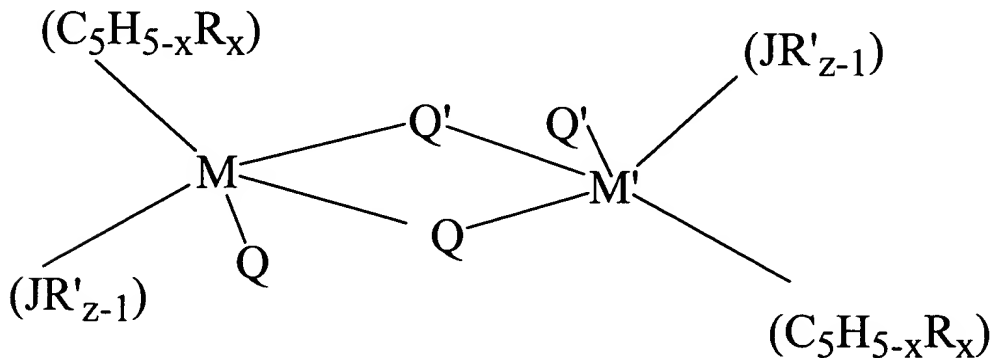
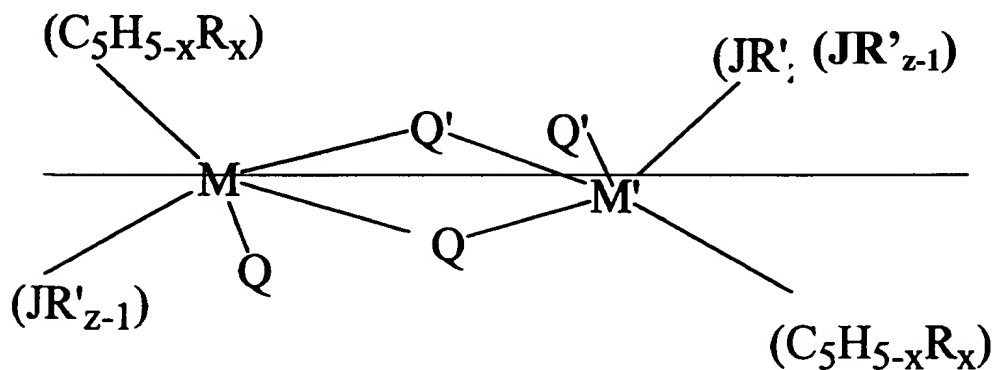
This listing of claims will replace all prior versions and listings of claims in the application:

1. - 26. (Cancelled)

27. (Currently amended) A compound having the general formula:



or



wherein M is Zr, Hf or Ti;

(C₅H_{5-x}R_x) is a cyclopentadienyl ring which is substituted with from zero to five substituent groups R, x is 0, 1, 2, 3, 4 or 5 denoting the degree of substitution, and each substituent group R is, independently, a radical selected from the group consisting of C₁-C₂₀ hydrocarbyl radicals, substituted C₁-C₂₀ hydrocarbyl radicals wherein one or more hydrogen atoms is replaced by a halogen atom, C₁-C₂₀ hydrocarbyl-substituted metalloid radicals wherein the metalloid is selected from the group IV A of the Periodic Table of Elements, and halogen radicals, or (C₅H_{5-x}R_x) is a cyclopentadienyl ring in which two adjacent R groups are joined forming a C₄-C₂₀ ring to give a saturated or unsaturated polycyclic cyclopentadienyl ligand;

(JR'_{z-1}) is a heteroatom ligand in which J is an element with a coordination number of three from Group V-A ~~or an element with a coordination number of two from Group VI-A~~ of the Periodic Table of Elements, each R' is, independently, a radical selected from a group consisting of C₁-C₂₀ hydrocarbyl radicals, substituted C₁-C₂₀ hydrocarbyl radicals where one or more hydrogen atoms is replaced by a halogen radical, and z is the coordination number of the element J;

each Q is, independently, selected from the group consisting of halogen, hydride or C₁-C₂₀ hydrocarbyl ~~a univalent anionic ligand or two Q's together are a divalent anionic chelating ligand~~, provided that Q is different from (C₅H_{5-x}R_x);

L is a neutral Lewis base where "w" is a number greater than 0 and up to 3;

M' has the same meaning as M; and

Q' has the same meaning as Q.

28. - 43. (cancelled)

44. (Currently amended) The compound of claim 27 wherein each Q is independently selected from the group consisting of halogen, ~~hydride or~~ hydride and C₁-C₂₀ hydrocarbyl.

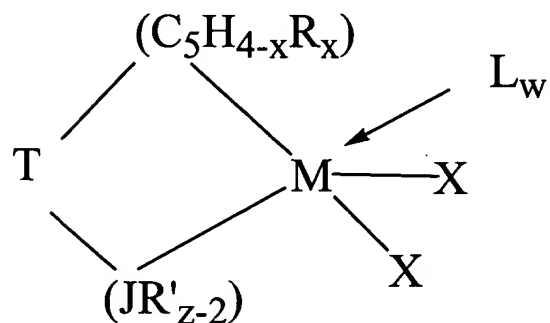
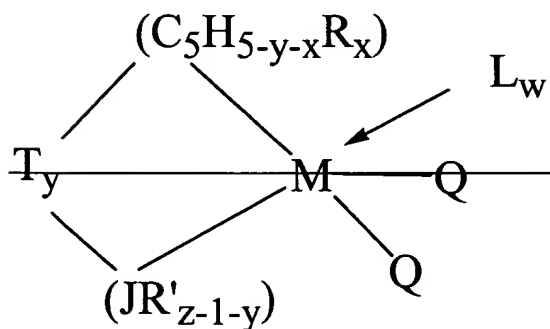
45. (Currently amended) The compound of claim 27 ~~herein~~ wherein each Q is independently selected from the group consisting of hydride, methyl, ethyl, propyl,

butyl, amyl, hexyl, heptyl, octyl, nonyl, decyl, cetyl, phenyl, chloro, bromo, fluoro, and iodo.

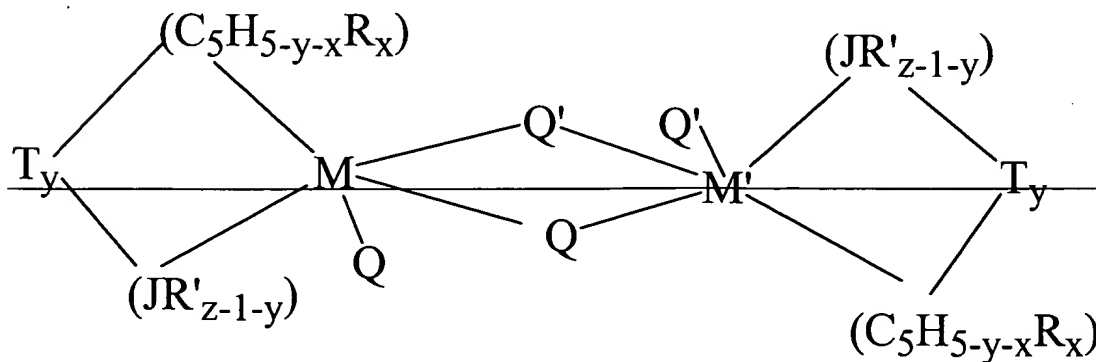
46. (Currently amended) The compound of claim 27 ~~herein~~ wherein M is Zr.

47. (Previously presented) The compound of claim 27 wherein M is Hf.

48. (Currently amended) A compound having the general formula



or



or a dimer thereof, wherein:

~~wherein M is Zr or Hf~~ M is Zr, Hf, or Ti;

~~M' has the same meaning as M;~~

~~(C₅H_{5-y-x}R_x)(C₅H_{4-x}R_x)~~ is a cyclopentadienyl ring which is substituted with from zero to ~~five~~ four substituent groups R, x is 0, 1, 2, 3, or 4 ~~4 or 5~~ denoting the degree of substitution, and each substituent group R is, independently, a radical selected from the group consisting of C₁-C₂₀ hydrocarbyl radicals, substituted C₁-C₂₀ hydrocarbyl radicals wherein one or more hydrogen atoms is replaced by a halogen atom, C₁-C₂₀ hydrocarbyl-substituted metalloid radicals wherein the metalloid is selected from the group ~~IV-A of the Periodic Table of Elements consisting of silicon and germanium, cyano,~~ and halogen radicals, or ~~(C₅H_{5-y-x}R_x)(C₅H_{4-x}R_x)~~ is a cyclopentadienyl ring in which two adjacent R substituents ~~groups~~ are joined forming a C₄-C₂₀ ring to give a saturated or unsaturated polycyclic cyclopentadienyl ligand;

~~(JR'_{z-1-y})(JR'_{z-2})~~ is a heteroatom ligand in which "J" is an element with a coordination number of three from ~~group~~ Group V-A or an element with a coordination number of two from Group VI-A of the Periodic Table of Elements, and ~~each~~ R' is a radical selected from the group consisting of C₁-C₂₀ hydrocarbyl radicals, substituted C₁-C₂₀ hydrocarbyl radicals ~~where~~ wherein one or more hydrogen atoms is replaced by a halogen atom ~~radical~~, and "z" is the coordination number of the element J;

~~each Q~~ X is, independently each occurrence, ~~a univalent an~~ anionic ligand group selected from the group consisting of hydride, halide, alkyl of up to 30 carbon atoms, alkoxy having up to a total of 30 carbon atoms and oxygen atoms, cyanide, azide, acetylacetonate, aryl having from 6 to 30 carbon atoms, aryl oxy having a total of from 7 to 30 carbon and oxygen atoms, norbornyl and benzyl; ~~or two Q's together are a divalent anionic chelating ligand, provided that Q is not a substituted or unsubstituted cyclopentadienyl ring;~~

~~Q' has the same meaning as Q;~~

~~y is 1 when w is greater than 0; T is a covalent bridging group containing a Group IV-A or V-A element~~ T is CR₂*, CR₂*CR₂*, SiR₂* or SiR₂*SiR₂*, where R* is selected

from the group consisting of hydrogen, C₁ to C₂₀-alkyl, haloalkyl having up to a total of 20 carbon and halogen atoms, aryl having from 6 to 20 carbon atoms, and haloaryl having a total of from 7 to 20 carbon and halogen atoms; and
L is a neutral Lewis base; and w is a number from 0 to 3. ~~where w denotes the number 0 or 1, and when w is 0 y is 1.~~

49. (Currently amended) The compound of claim 48 wherein each Q X is independently selected from the group consisting of ~~halogen, hydride or C₁ to C₂₀ hydrocarbyl~~ halide, hydride and alkyl of up to 30 carbon atoms.

50. (Currently amended) The compound of claim 48 ~~herein~~ wherein each Q X is independently selected from the group consisting of hydride, methyl, ethyl, propyl, butyl, amyl, hexyl, heptyl, octyl, nonyl, decyl, cetyl, phenyl, chloro, bromo, fluoro, and iodo.

51. (Currently amended) The compound of claim 48 ~~herein~~ wherein M is Zr.

52. (Previously presented) The compound of claim 48 wherein M is Hf.

53. (Previously presented) The compound of claim 48 wherein M is Ti.

54. (Previously presented) The compound of claim 48 wherein J is nitrogen, oxygen, phosphorus, or sulfur.

55. (Previously resented) The compound of claim 48 wherein J is nitrogen.

56. (Currently amended) The compound of claim 48 wherein ~~(C₅H₅-y-xRx)~~ (C₅H₄-xRx) is indenyl, tetrahydroindenyl, fluorenyl, ~~or~~ or octahydrofluorenyl.

57. (Cancelled)

58. (Cancelled)

59. (Cancelled)

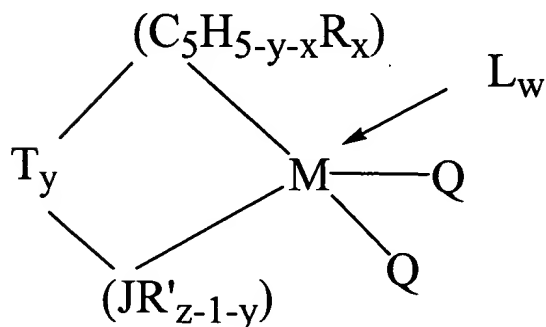
60. (Currently amended) The compound of claim 48 wherein T is methylene
 of or ethylene.

61. (Previously presented) The compound of claim 48 wherein T is
 dimethylsilyl.

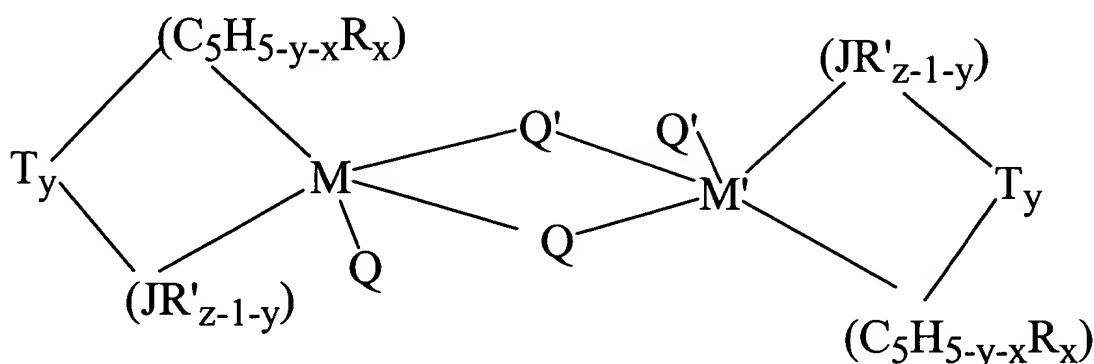
62. (Currently amended) The compound of claim 48 wherein T is
~~diphenylsilyl~~ diphenylsilyl.

63. (Currently amended) The compound of ~~claim 1~~ claim 48 wherein X is a
halide. Q is a halogen or C1 to C20 hydrocarbyl radical.

64. (New) A compound having the general formula



or



wherein M is Zr, Hf, or Ti;

M' has the same meaning as M;

(C₅H_{5-y-x}R_x) is a cyclopentadienyl ring which is substituted with from zero to five substituent groups R, x is 0, 1, 2, 3, 4 or 5 denoting the degree of substitution, and each substituent group R is, independently, a radical selected from the group consisting of C₁-C₂₀ hydrocarbyl radicals, substituted C₁-C₂₀ hydrocarbyl radicals wherein one or more hydrogen atoms is replaced by a halogen atom, C₁-C₂₀ hydrocarbyl-substituted metalloid radicals wherein the metalloid is selected from the group IV A of the Periodic Table of Elements and halogen radicals, or (C₅H_{5-y-x}R_x) is a cyclopentadienyl ring in which two adjacent R substituents are joined forming a C₄-C₂₀ ring to give a saturated or unsaturated polycyclic cyclopentadienyl ligand;

(JR'_{z-1-y}) is a heteroatom ligand in which J is nitrogen, phosphorus, oxygen, or sulfur, and R' is a radical selected from the group consisting of C₁-C₂₀ hydrocarbyl radicals, substituted C₁-C₂₀ hydrocarbyl radicals where one or more hydrogen atoms is replaced by a halogen radical, and z is 3 when J is nitrogen or phosphorus or z is 2 when J is oxygen or sulfur;

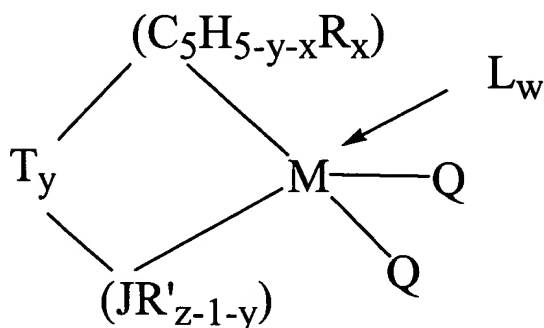
each Q is, independently, a univalent anionic ligand or two Q's together are a divalent anionic chelating ligand, provided that Q is not a substituted or unsubstituted cyclopentadienyl ring;

Q' has the same meaning as Q;

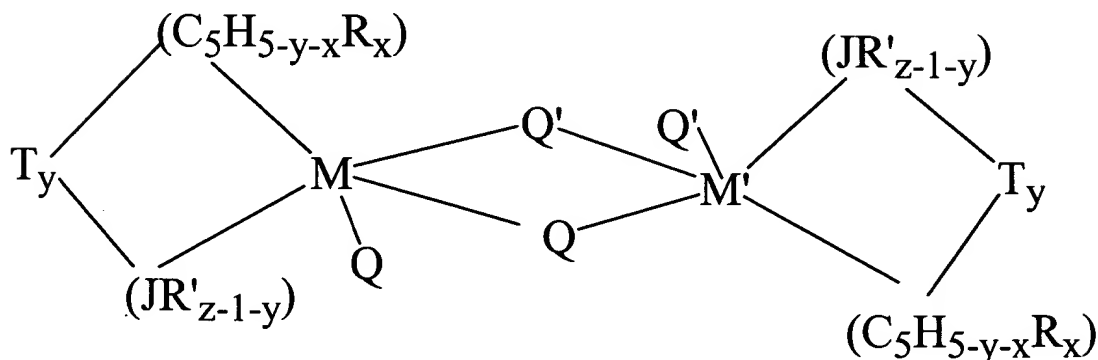
y is 0 or 1 when w is greater than 0; T is a covalent bridging group containing a Group IV-A or V-A element; and

L is a neutral Lewis base, where w denotes the number 0 or 1, and when w is 0 y is 1.

65. (New) A compound having the general formula



or



wherein M is Zr, Hf, or Ti;

M' has the same meaning as M;

(C₅H_{5-y-x}R_x) is a cyclopentadienyl ring which is substituted with from zero to five substituent groups R, x is 0, 1, 2, 3, 4 or 5 denoting the degree of substitution, and each substituent group R is, independently, a radical selected from the group consisting of C₁-C₂₀ hydrocarbyl radicals, substituted C₁-C₂₀ hydrocarbyl radicals wherein one or more hydrogen atoms is replaced by a halogen atom, C₁-C₂₀ hydrocarbyl-substituted metalloid radicals wherein the metalloid is selected from the group IV A of the Periodic Table of Elements and halogen radicals, or (C₅H_{5-y-x}R_x) is a cyclopentadienyl ring in which two

adjacent R substituents are joined forming a C₄-C₂₀ ring to give a saturated or unsaturated polycyclic cyclopentadienyl ligand;

(JR'_{z-1-y}) is a heteroatom ligand in which J is nitrogen, and R' is a radical selected from the group consisting of C₁-C₂₀ hydrocarbyl radicals, substituted C₁-C₂₀ hydrocarbyl radicals where one or more hydrogen atoms is replaced by a halogen radical, and z is 3;

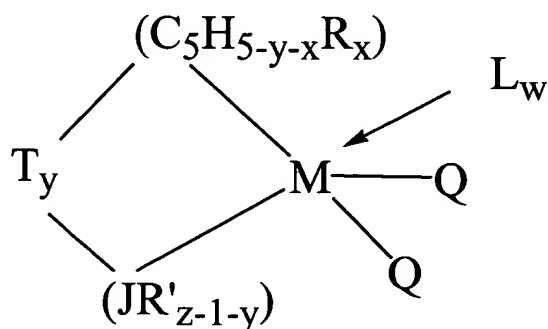
each Q is, independently, a univalent anionic ligand or two Q's together are a divalent anionic chelating ligand, provided that Q is not a substituted or unsubstituted cyclopentadienyl ring;

Q' has the same meaning as Q;

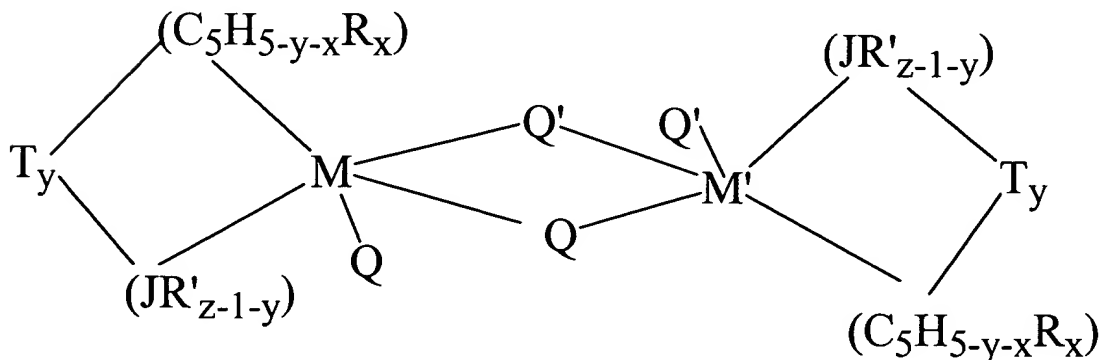
y is 0 or 1 when w is greater than 0; T is a covalent bridging group containing a Group IV-A or V-A element; and

L is a neutral Lewis base, where w denotes the number 0 or 1, and when w is 0 y is 1.

66. (New) A compound having the general formula



or



wherein M is Zr, or Hf;

M' has the same meaning as M;

(C₅H_{5-y-x}R_x) is a cyclopentadienyl ring which is substituted with from zero to five substituent groups R, x is 0, 1, 2, 3, 4 or 5 denoting the degree of substitution, and each substituent group R is, independently, a radical selected from the group consisting of C₁-C₂₀ hydrocarbyl radicals, substituted C₁-C₂₀ hydrocarbyl radicals wherein one or more hydrogen atoms is replaced by a halogen atom, C₁-C₂₀ hydrocarbyl-substituted metalloid radicals wherein the metalloid is selected from the group IV A of the Periodic Table of Elements and halogen radicals, or (C₅H_{5-y-x}R_x) is a cyclopentadienyl ring in which two adjacent R substituents are joined forming a C₄-C₂₀ ring to give a saturated or unsaturated polycyclic cyclopentadienyl ligand;

(JR'_{z-1-y}) is a heteroatom ligand in which J is an element with a coordination number of three from Group V-A or an element with a coordination number of two from Group VI-A of the Periodic Table of Elements, and each R' is a radical selected from the group consisting of C₁-C₂₀ hydrocarbyl radicals, substituted C₁-C₂₀ hydrocarbyl radicals where one or more hydrogen atoms is replaced by a halogen radical, and z is the coordination number of the element J;

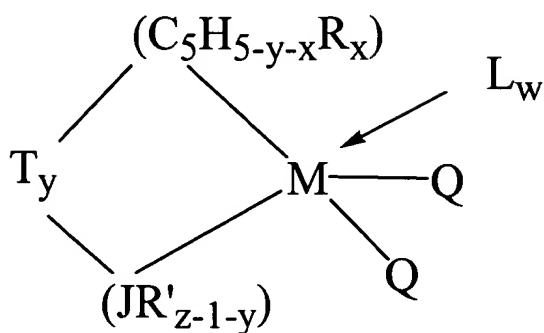
each Q is, independently, a univalent anionic ligand or two Q's together are a divalent anionic chelating ligand, provided that Q is not a substituted or unsubstituted cyclopentadienyl ring;

Q' has the same meaning as Q;

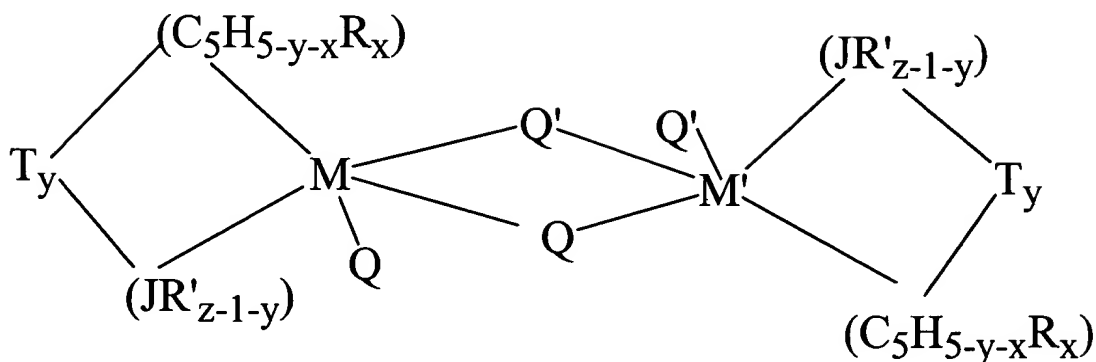
y is 0 or 1 when w is greater than 0; T is a covalent bridging group containing a Group IV-A or V-A element; and

L is a neutral Lewis base, where w denotes the number 0 or 1, and when w is 0 y is 1.

67. (New) A compound having the general formula



or



wherein M is Ti, Zr, or Hf;

M' has the same meaning as M;

(C₅H_{5-y-x}R_x) is a cyclopentadienyl ring which is substituted with from zero to five substituent groups R, x is 0, 1, 2, 3, 4 or 5 denoting the degree of substitution, and each substituent group R is, independently, a radical selected from the group consisting of C₁-C₂₀ hydrocarbyl radicals, substituted C₁-C₂₀ hydrocarbyl radicals wherein one or more hydrogen atoms is replaced by a halogen atom, C₁-C₂₀ hydrocarbyl-substituted metalloid radicals wherein the metalloid is selected from the group IV A of the Periodic Table of Elements and halogen radicals, or (C₅H_{5-y-x}R_x) is a cyclopentadienyl ring in which two adjacent R substituents are joined forming a C₄-C₂₀ ring to give a saturated or unsaturated polycyclic cyclopentadienyl ligand;

(JR'_{z-1-y}) is a heteroatom ligand in which J is an element with a coordination number of three from Group V-A or an element with a coordination number of two from

Group VI-A of the Periodic Table of Elements, and each R' is a radical selected from the group consisting of C₁-C₂₀ hydrocarbyl radicals, substituted C₁-C₂₀ hydrocarbyl radicals where one or more hydrogen atoms is replaced by a halogen radical, and z is the coordination number of the element J;

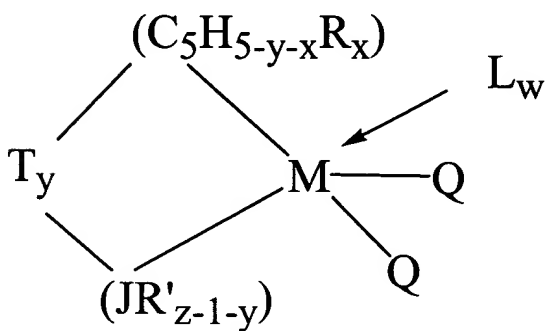
each Q is independently selected from the group consisting of halogen, hydride or a substituted or unsubstituted C₁-C₂₀ hydrocarbyl, alkoxide, aryloxy, amide, arylamide, phosphide, or arylphosphide, provided that provided that Q is not a substituted or unsubstituted cyclopentadienyl ring, or both Q together are an alkylidene or a cyclometallated hydrocarbyl;

Q' has the same meaning as Q;

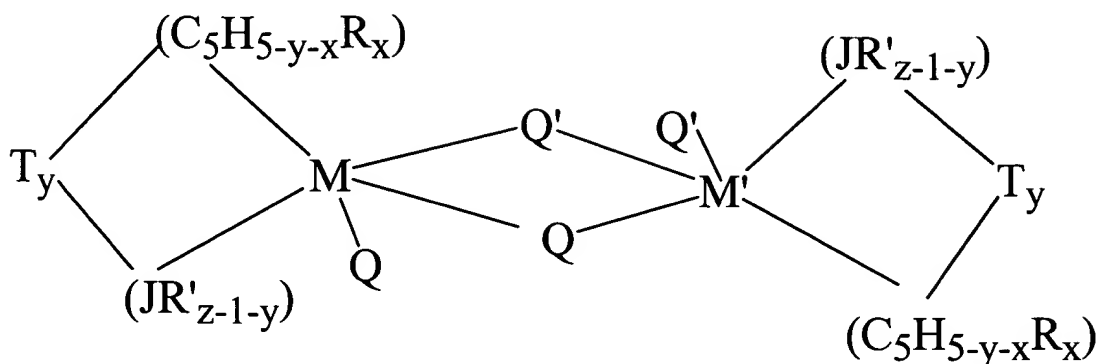
y is 0 or 1 when w is greater than 0; T is a covalent bridging group containing a Group IV-A or V-A element; and

L is a neutral Lewis base, where w denotes the number 0 or 1, and when w is 0 y is 1.

68. (New) A compound having the general formula



or



wherein M is Zr, Hf, or Ti;

M' has the same meaning as M;

(C₅H_{5-y-x}R_x) is a cyclopentadienyl ring which is substituted with from zero to five substituent groups R, x is 0, 1, 2, 3, 4 or 5 denoting the degree of substitution, and each substituent group R is, independently, a radical selected from the group consisting of C₁-C₂₀ hydrocarbyl radicals, substituted C₁-C₂₀ hydrocarbyl radicals wherein one or more hydrogen atoms is replaced by a halogen atom, C₁-C₂₀ hydrocarbyl-substituted metalloid radicals wherein the metalloid is selected from the group IV A of the Periodic Table of Elements or (C₅H_{5-y-x}R_x) is a cyclopentadienyl ring in which two adjacent R groups are joined forming a C₄-C₂₀ ring to give a saturated or unsaturated polycyclic cyclopentadienyl ligand;

(JR'_{z-1-y}) is a heteroatom ligand in which J is an element with a coordination number of three from Group V-A or an element with a coordination number of two from Group VI-A of the Periodic Table of Elements, and each R' is a radical selected from the group consisting of C₁-C₂₀ hydrocarbyl radicals, substituted C₁-C₂₀ hydrocarbyl radicals where one or more hydrogen atoms is replaced by a halogen atom, and z is the coordination number of the element J;

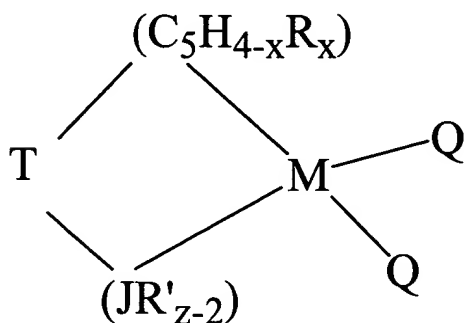
each Q is, independently, a univalent anionic ligand or two Q's together are a divalent anionic chelating ligand, provided that Q is not a substituted or unsubstituted cyclopentadienyl ring;

Q' has the same meaning as Q;

y is 0 or 1 when w is greater than 0, y is 1 when w is 0; T is a covalent bridging group containing a Group IV-A or V-A element and
L is a Lewis base; where w denotes a number from 0 to 3.

69.(new) The compound of claim 68 wherein each Q is a halogen or hydrocarbyl radical.

70. (New) A compound represented by general formula



M is Zr, Hf, or Ti;

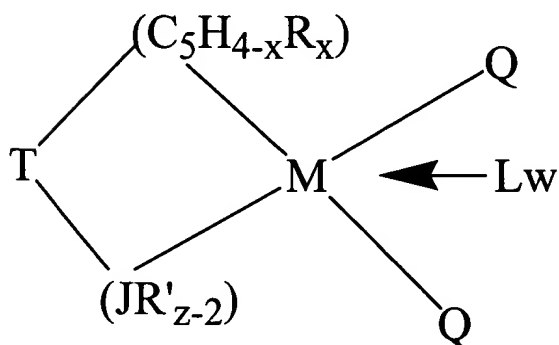
$(C_5H_{4-x}R_x)$ is a cyclopentadienyl ring which is substituted with from zero to four substituent groups R, x is 0, 1, 2, 3, or 4 denoting the degree of substitution, and each substituent group R is, independently, a radical selected from the group consisting of C₁-C₂₀ hydrocarbyl radicals, substituted C₁-C₂₀ hydrocarbyl radicals wherein one or more hydrogen atoms is replaced by a halogen atom, and halogen radicals, or $(C_5H_{4-x}R_x)$ is a cyclopentadienyl ring in which two adjacent R substituents are joined forming a C₄-C₂₀ ring to give a saturated or unsaturated polycyclic cyclopentadienyl ligand;

(JR'_{z-2}) is a heteroatom ligand in which J is an element with a coordination number of three from Group V-A, and R' is a radical selected from the group consisting of C₁-C₂₀ hydrocarbyl radicals, substituted C₁-C₂₀ hydrocarbyl radicals where one or more hydrogen atoms is replaced by a halogen radical, and z is 3;

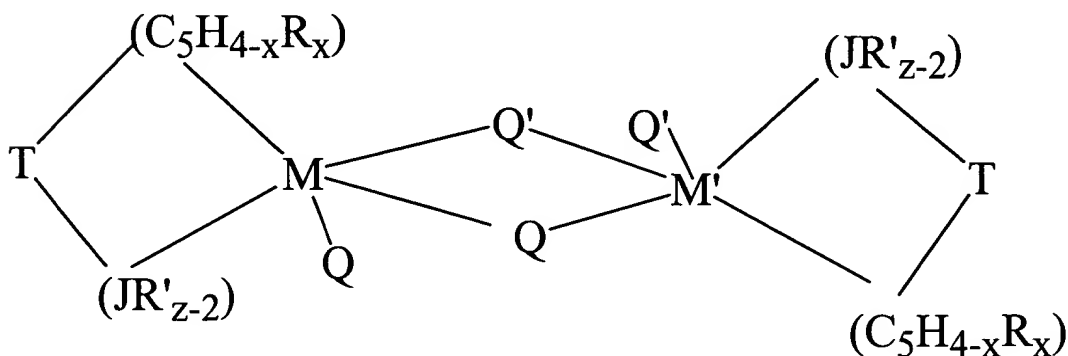
each Q is, independently, a univalent anionic ligand group or two Q's together are a divalent anionic chelating ligand, provided that Q is not a substituted or unsubstituted cyclopentadienyl ring; and

T is a covalent bridging group containing a Group IV-A or V-A element.

71 (new) A compound having the general formula:



or



wherein M is Zr, Hf, or Ti;

M' has the same meaning as M;

(C₅H_{4-x}R_x) is a cyclopentadienyl ring which is substituted with from zero to four substituent groups R, x is 0, 1, 2, 3, or 4 denoting the degree of substitution, and each substituent group R is, independently, a radical selected from the group consisting of C₁-C₂₀ hydrocarbyl radicals, substituted C₁-C₂₀ hydrocarbyl radicals wherein one or more hydrogen atoms is replaced by a halogen atom, and halogen radicals, or (C₅H_{4-x}R_x) is a

cyclopentadienyl ring in which two adjacent R substituents are joined forming a C₄-C₂₀ ring to give a saturated or unsaturated polycyclic cyclopentadienyl ligand;

(JR'_{z-2}) is a heteroatom ligand in which J is an element with a coordination number of three from Group V-A or an element with a coordination number of two from Group VI-A of the Periodic Table of Elements, and R' is a radical selected from the group consisting of C₁-C₂₀ hydrocarbyl radicals, substituted C₁-C₂₀ hydrocarbyl radicals where one or more hydrogen atoms is replaced by a halogen radical, and z is the coordination number of the element J;

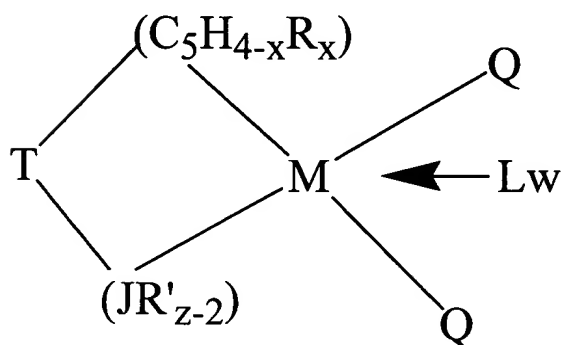
each Q is, independently, a univalent anionic ligand or two Q's together are a divalent anionic chelating ligand, provided that Q is not a substituted or unsubstituted cyclopentadienyl ring;

Q' has the same meaning as Q;

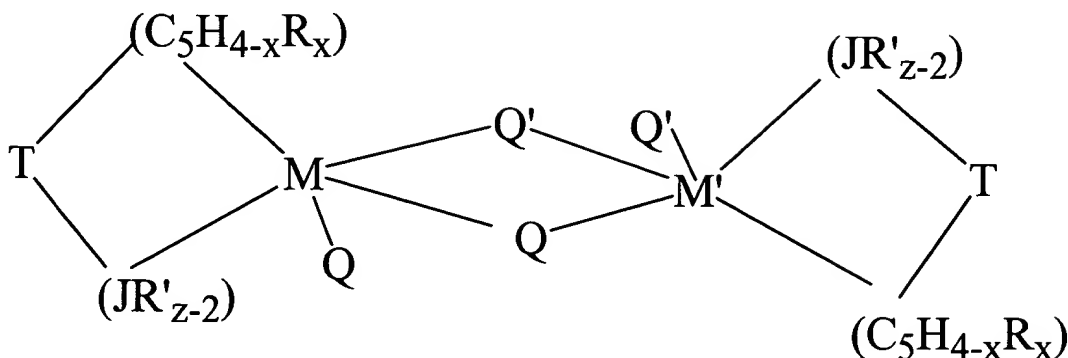
T is a covalent bridging group selected from the group consisting of dialkyl, alkylaryl, or diaryl substituted silicon or germanium radicals; and

L is a neutral Lewis base where w denotes the number 0 or 1.

72. (new) A compound having the general formula:



or



wherein M is Zr, Hf, or Ti;

M' has the same meaning as M;

(C₅H_{4-x}R_x) is a cyclopentadienyl ring which is substituted with from zero to four substituent groups R, x is 0, 1, 2, 3, or 4 denoting the degree of substitution, and each substituent group R is, independently, a radical selected from the group consisting of C₁-C₂₀ hydrocarbyl radicals, substituted C₁-C₂₀ hydrocarbyl radicals wherein one or more hydrogen atoms is replaced by a halogen atom, and halogen radicals, or (C₅H_{4-x}R_x) is a cyclopentadienyl ring in which two adjacent R substituents are joined forming a C₄-C₂₀ ring to give a saturated or unsaturated polycyclic cyclopentadienyl ligand;

(JR'_{z-2}) is a heteroatom ligand in which J is an element with a coordination number of three from Group V-A or an element with a coordination number of two from Group VI-A of the Periodic Table of Elements, and R' is a radical selected from the group consisting of C₁-C₂₀ hydrocarbyl radicals, substituted C₁-C₂₀ hydrocarbyl radicals where one or more hydrogen atoms is replaced by a halogen radical, and z is the coordination number of the element J;

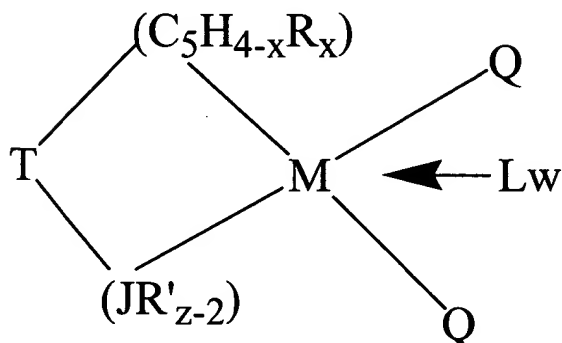
each Q is, independently, a univalent anionic ligand or two Q's together are a divalent anionic chelating ligand, provided that Q is not a substituted or unsubstituted cyclopentadienyl ring;

Q' has the same meaning as Q;

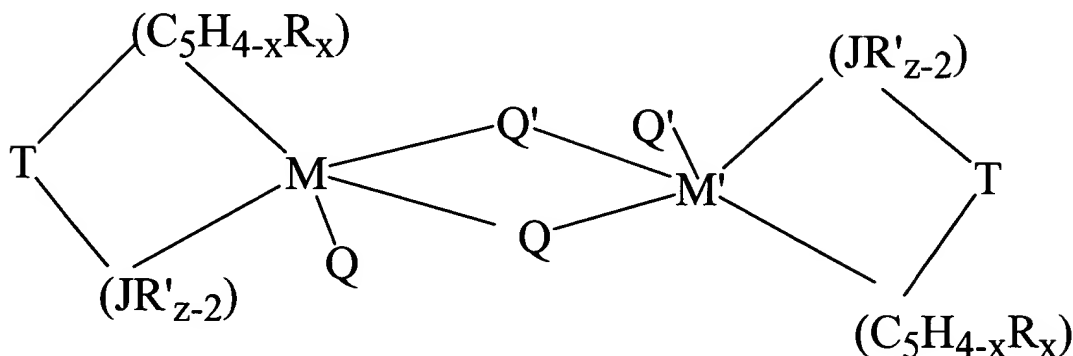
T is a covalent bridging group selected from the group consisting of substituted or unsubstituted methylene or ethylene radicals; and

L is a neutral Lewis base where w denotes the number 0 or 1.

73. (new) A compound having the general formula:



or



wherein M is Zr, Hf, or Ti;

M' has the same meaning as M;

(C₅H_{4-x}R_x) is a cyclopentadienyl ring which is substituted with from zero to four substituent groups R, x is 0, 1, 2, 3, or 4 denoting the degree of substitution, and each substituent group R is, independently, a radical selected from the group consisting of methyl, ethyl, propyl, butyl, octyl, benzyl, phenyl, trimethylgermyl, trimethylstannyl, triethylplumbyl, trifluoromethyl, trimethylsilyl, triethylsilyl, ethyldimethylsilyl, methyldiethylsilyl, and triphenylgermyl, or (C₅H_{4-x}R_x) is a cyclopentadienyl ring in which two adjacent R substituents are joined forming a C₄-C₂₀ ring to give a saturated or unsaturated polycyclic cyclopentadienyl ligand;

(JR'_{z-2}) is a heteroatom ligand selected from the group consisting of *t*-butylamido, phenylamido, *p*-*n*-butylphenylamido, cyclohexylamido, perfluorophenylamido, *n*-

butylamido, methylamido, ethylamido, *n*-propylamido, isopropylamido, benzylamido, *t*-butylphosphido, ethylphosphido, phenylphosphido, and cyclohexylphosphido, and *z* is 3;

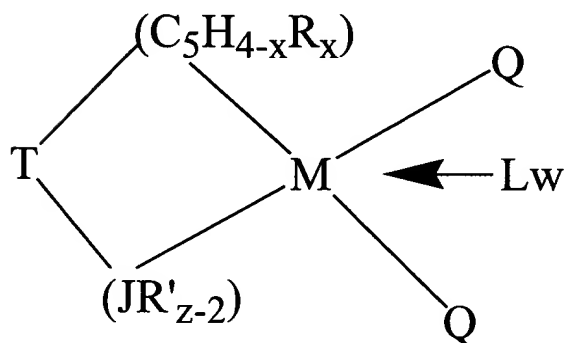
each *Q* is, independently, selected from the group consisting of hydride, methyl, ethyl, propyl, butyl, amyl, hexyl, heptyl, octyl, nonyl, decyl, cetyl, phenyl, chloro, bromo, fluoro, iodo, methoxy, ethoxy, propoxy, butoxy, phenoxy, methylphenoxy, dimethylamido, diethylamido, methylethylamido, dibutylamido, dipropylamido, diphenylamido, diphenylphosphido, dicyclohexylphosphido, diethylphosphido, and dimethylphosphido;

Q' has the same meaning as *Q*;

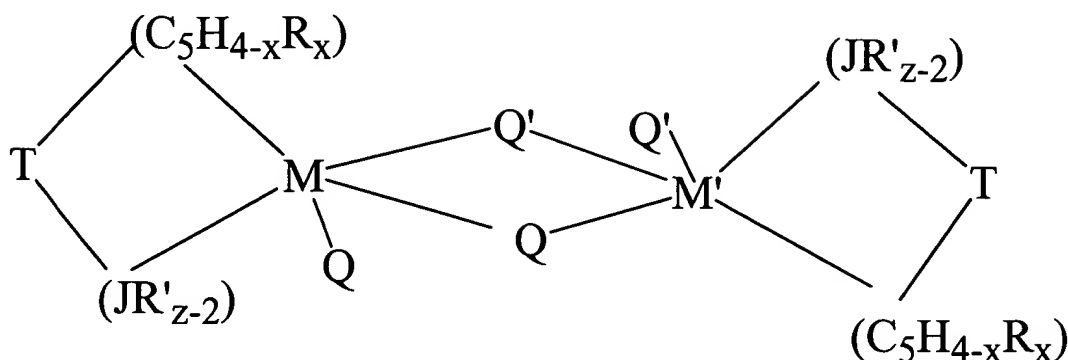
T is a covalent bridging group selected from the group consisting of dimethylsilyl, diethylsilyl, di-*n*-propylsilyl, diisopropylsilyl, di-*n*-butylsilyl, di-*t*-butylsilyl, di-*n*-hexylsilyl, methylphenylsilyl, ethylmethylsilyl, diphenylsilyl, *n*-hexylmethylsilyl, cyclopentamethylenesilyl, cyclotetramethylenesilyl, cyclotrimethylenesilyl, dimethylgermyl, and diethylgermyl; and

L is a neutral Lewis base where *w* denotes the number 0 or 1.

74. (new) A compound having the general formula:



or



wherein M is Zr, Hf, or Ti;

M' has the same meaning as M;

(C₅H_{4-x}R_x) is a cyclopentadienyl ring which is substituted with from zero to four substituent groups R, x is 0, 1, 2, 3, or 4 denoting the degree of substitution, and each substituent group R is, independently, a radical selected from the group consisting of methyl, ethyl, propyl, butyl, octyl, benzyl, phenyl, trimethylgermyl, trimethylstannyl, triethylplumblyl, trifluoromethyl, trimethylsilyl, triethylsilyl, ethyldimethylsilyl, methyldiethylsilyl, and triphenylgermyl, or (C₅H_{4-x}R_x) is a cyclopentadienyl ring in which two adjacent R substituents are joined forming a C₄-C₂₀ ring to give a saturated or unsaturated polycyclic cyclopentadienyl ligand;

(JR'_{z-2}) is a heteroatom ligand selected from the group consisting of *t*-butylamido, phenylamido, *p*-*n*-butylphenylamido, cyclohexylamido, perfluorophenylamido, *n*-butylamido, methylamido, ethylamido, *n*-propylamido, isopropylamido, benzylamido, *t*-butylphosphido, ethylphosphido, phenylphosphido, and cyclohexylphosphido, and z is 3;

each Q is, independently, selected from the group consisting of hydride, methyl, ethyl, propyl, butyl, amyl, hexyl, heptyl, octyl, nonyl, decyl, cetyl, phenyl, chloro, bromo, fluoro, iodo, methoxy, ethoxy, propoxy, butoxy, phenoxy, methylphenoxy, dimethylamido, diethylamido, methylethylamido, dibutylamido, dipropylamido, diphenylamido, diphenylphosphido, dicyclohexylphosphido, diethylphosphido, and dimethylphosphido;

Q' has the same meaning as Q;

T is a covalent bridging group selected from the group consisting of methylene, dimethylmethylene, diethylmethylene, ethylene, dimethylethylene, diethylmethylene, and dipropylethylene; and

L is a neutral Lewis base where w denotes the number 0 or 1.

75.(New) Dimethylsilyl(tetramethylcyclopentadienyl)(tert-butylamido) M dichloride, where M is titanium, zirconium or hafnium.

76.(New) Dimethylsilyl(tetramethylcyclopentadienyl)(tert-butylamido) zirconium dichloride.

77. (New) The compound of claim 70 wherein q is independently selected from the group consisting of halogen, hydride and C₁ to C₂₀ hydrocarbyl.

78. (New) The compound of claim 71 wherein q is independently selected from the group consisting of halogen, hydride or C₁ to C₂₀ hydrocarbyl.

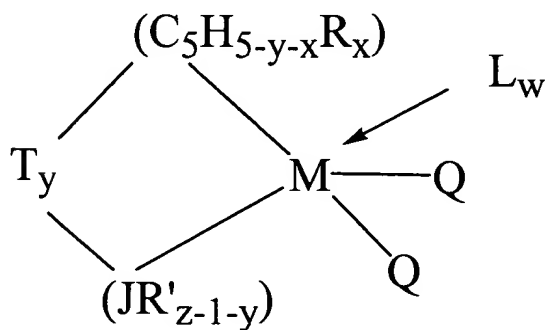
79.(New) The compound of claim 72 wherein q is independently selected from the group consisting of halogen, hydride or C₁ to C₂₀ hydrocarbyl.

80. (New) The compound of claim 70 wherein each Q is independently selected from the group consisting of hydride, methyl, ethyl, propyl, butyl, amyl, hexyl, heptyl, octyl, nonyl, decyl, cetyl, phenyl, chloro, bromo, and iodo.

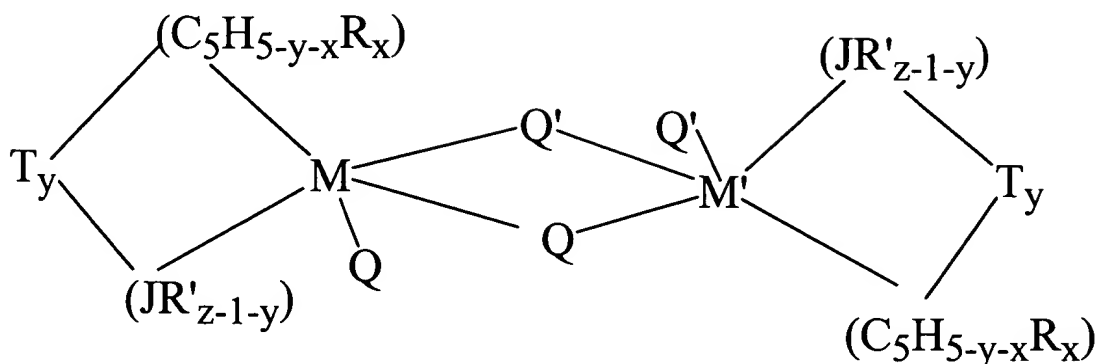
81. (New) The compound of claim 71 wherein each Q is independently selected from the group consisting of hydride, methyl, ethyl, propyl, butyl, amyl, hexyl, heptyl, octyl, nonyl, decyl, cetyl, phenyl, chloro, bromo, and iodo.

82.(New) The compound of claim 72 wherein each Q is independently selected from the group consisting of hydride, methyl, ethyl, propyl, butyl, amyl, hexyl, heptyl, octyl, nonyl, decyl, cetyl, phenyl, chloro, bromo, and iodo.

83. (New) A process for the polymerization of one or more alpha olefins comprising conducting the polymerization in the presence of a catalyst system comprising (A) the compound of claim 48 and (B) an alumoxane.
84. (New) The process of claim 83 wherein the mole ratio of Al:M is from 10:1 to 20,000:1.
85. (New) The process of claim 83 wherein the one or more alpha olefins is ethylene.
86. (New) The process of claim 83 wherein the one or more alpha olefins is propylene.
87. (New) The process of claim 83 wherein the one or more alpha olefins is (1) ethylene in combination with an alpha olefin having 3 to 20 carbon atoms, (2) propylene in combination with ethylene and/or C4 or higher alpha-olefins and diolefins, or (3) butene in combination with ethylene and/or C4 or higher alpha-olefins and diolefins.
88. (New) A process for the polymerization of one or more alpha olefins comprising conducting the polymerization in the presence of a catalyst system comprising:
- (A) a Group IV B transition metal component of the formula:



or



wherein M is Zr, Hf or Ti;

M' has the same meaning as M;

(C₅H_{5-y-x}R_x) is a cyclopentadienyl ring which is substituted with from zero to five groups R, x is 0, 1, 2, 3, 4 or 5 denoting the degree of substitution, and

each R is, independently, a radical selected from the group consisting of C₁-C₂₀ hydrocarbyl radicals, substituted C₁-C₂₀ hydrocarbyl radicals wherein one or more hydrogen atoms is replaced by a halogen atom, C₁-C₂₀ hydrocarbyl-substituted metalloid radicals wherein the metalloid is selected from the Group IV A of the Periodic Table of Elements, and halogen radicals, or (C₅H_{5-y-x}R_x) is a cyclopentadienyl ring in which two adjacent R-groups are joined forming a C₄-C₂₀ ring to give a saturated or unsaturated polycyclic ligand;

(JR'_{z-1-y}) is a heteroatom ligand in which J is an element with a coordination number of three from Group V-A or an element with a coordination number of two from Group VI-A of the Periodic Table of Elements, and each R' is, independently, a radical selected from the group consisting of C₁-C₂₀ hydrocarbyl radicals, substituted C₁-C₂₀ hydrocarbyl radicals where one or more hydrogen atoms is replaced by a halogen atom, and z is the coordination number of the element J;

each Q is, independently, any univalent anionic ligand or two Q's together are a divalent anionic chelating ligand, provided that Q is different from (C₅H_{5-x}R_x);

Q' has the same meaning as Q;

y is 0 or 1 when w is greater than 0; y is 1 when w is 0, when y is 1, T is a covalent bridging group containing a Group IV-A or V-A element; and

L is a Lewis base where w denotes, a number form 0 to 3;
(B) an alumoxane.

89. (New) The process of claim 88 wherein the heteroatom ligand group J element is nitrogen, phosphorus, oxygen or sulfur.

90. (New) The process of claim 88 wherein Q is a halogen or hydrocarbyl radical.

91. (New) The process of claim 88 wherein the heteroatom ligand group J element is nitrogen.

92. (New) The process of claim 88 wherein M is Zr or Hf.

93. (New) The process of claim 88 wherein the mole ratio of Al:M is from 10:1 to 20,000:1.

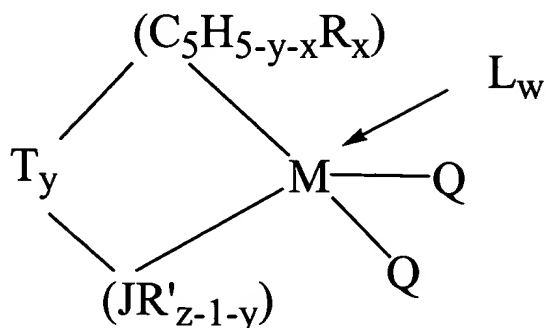
94. (New) the process of claim 88 wherein Q is independently halogen, hydride, or a substituted or unsubstituted C1 to C20 hydrocarbyl, alkoxide, aryl oxide, amide, aryl amide, phosphide or aryl phosphide, provided that where any Q is a hydrocarbyl such Q is different from (C₅H_{5-y-x}R_x) or both together are an alylidene or a cyclometallated hydrocarbyl.

95. (New) The process of claim 88 wherein the olefins are selected from ethylene, alpha-olefin having from 3 to 20 carbon atoms, and combinations thereof.

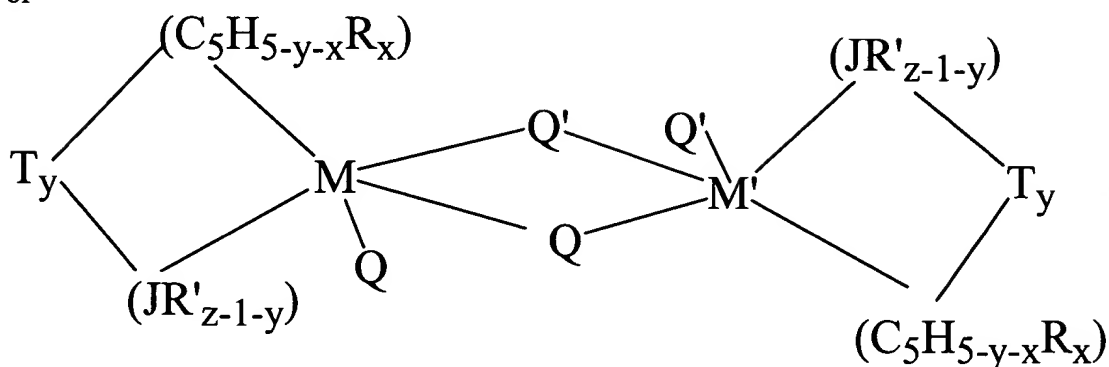
96. (New) The process of claim 88 wherein the polymerization conducted is a homopolymerization.

97. (New) The process of claim 88 wherein the polymerization conducted is a copolymerization.

98. (New) The process of claim 88 wherein the olefins are selected from propylene, butene, diolefins, and combinations thereof.
99. (New) The process of claim 88 wherein the olefin is styrene.
100. (New) The process of claim 88 wherein the process utilized is liquid phase, high pressure fluid phase, or gas phase.
101. (New) The process of claim 88 wherein the polymerization process conducted is selected from slurry, solution, suspension, or bulk phase polymerization.
102. (New) The process of claim 100 wherein the process is employed in series.
103. (New) The process of claim 101 wherein the process is employed in series.
104. (New) The process of claim 88 wherein the polymer produced has an Mw/Mn of a value below about 4.
105. (New) A process for the polymerization of one or more alpha olefins comprising conducting the polymerization in the presence of a catalyst system comprising:
- (A) a Group IV B transition metal component of the formula:



or



wherein M is Zr, Hf or Ti;

M' has the same meaning as M ;

$(C_5H_{5-y-x}R_x)$ is a cyclopentadienyl ring which is substituted with from zero to four substituent groups R , x is 0, 1, 2, 3 or 4 denoting the degree of substitution, and each substituent group R is, independently, a radical selected from the group consisting of C_1 - C_{20} hydrocarbyl radicals, substituted C_1 - C_{20} hydrocarbyl radicals wherein one or more hydrogen atoms is replaced by a halogen atom, C_1 - C_{20} hydrocarbyl-substituted metalloid radicals wherein the metalloid is selected from the group IV A of the Periodic Table of Elements, and halogen radicals, or $(C_5H_{5-y-x}R_x)$ is a cyclopentadienyl ring in which two adjacent R -groups are joined forming a C_4 - C_{20} ring to give a saturated or unsaturated polycyclic ligand;

(JR'_{z-1-y}) is a heteroatom ligand in which J is an element with a coordination number of three from group V-A or an element with a coordination number of two from Group VI-A of the Periodic Table of Elements, and each R' is a radical selected from the group consisting of C_1 - C_{20} hydrocarbyl radicals, substituted C_1 - C_{20} hydrocarbyl radicals where

one or more hydrogen atoms is replaced by a halogen radical, and z is the coordination number of the element J;

each Q is, independently, a univalent anionic ligand or two Q's together are a divalent anionic chelating ligand, provided that Q is different from $(C_5H_{5-x}R_x)$;

Q' has the same meaning as Q;

y is 1;

T is a covalent bridging group containing a Group IV-A or V-A element; and

L is a neutral Lewis base where w denotes the number 0 or 1;

(B) an alumoxane.

106. (New) The process of claim 105 wherein each Q is, independently, a substituted or unsubstituted C_1 - C_{20} hydrocarbyl, phosphide or arylphosphide radical, provided that Q is not a substituted or unsubstituted cyclopentadienyl ring, or both Q together are an alkylidene or a cyclometallated hydrocarbyl.

107. (New) The process of claim 105 wherein the heteroatom ligand group J element is nitrogen, phosphorous, oxygen or sulfur.

108. (New) The process of claim 105 wherein Q is substituted or unsubstituted C_1 to C_{20} hydrocarbyl radical.

109. (New) The process of claim 105 wherein the heteroatom ligand group J element is nitrogen.

110. (New) The process of claim 105 wherein the mole ratio of Al:M is from 10:1 to 20,000:1.

111. (New) The process of claim 105 wherein the alpha olefin is (1) ethylene, (2) propylene, (3) ethylene in combination with an alpha olefin having 3 to 20 carbon atoms, (4) propylene in combination with ethylene and/or C_4 or higher alpha-olefins and diolefins, or (5) butene in combination with ethylene and/or C_4 or higher alpha-olefins and diolefins.

112. (New) The process of claim 105 wherein both Q are selected from the group consisting of: methyl, ethyl, propyl, butyl, amyl, isoamyl, hexyl, isobutyl, heptyl, octyl, nonyl, decyl, cetyl, 2-ethylhexyl, and phenyl.

113. (New) The process of claim 105 wherein both Q are methyl.

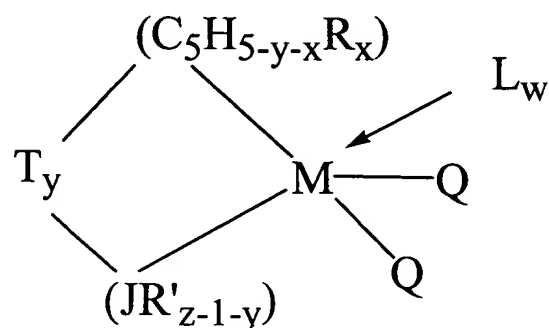
114. (New) The process of claim 105 wherein both Q are selected from the group consisting of: diphenylphosphide, dicyclohexylphosphide, diethylphosphide, dimethylphosphide, methyldiene, ethyldiene and propyldiene.

115. (New) The process of claim 105 wherein the alpha olefin is ethylene.

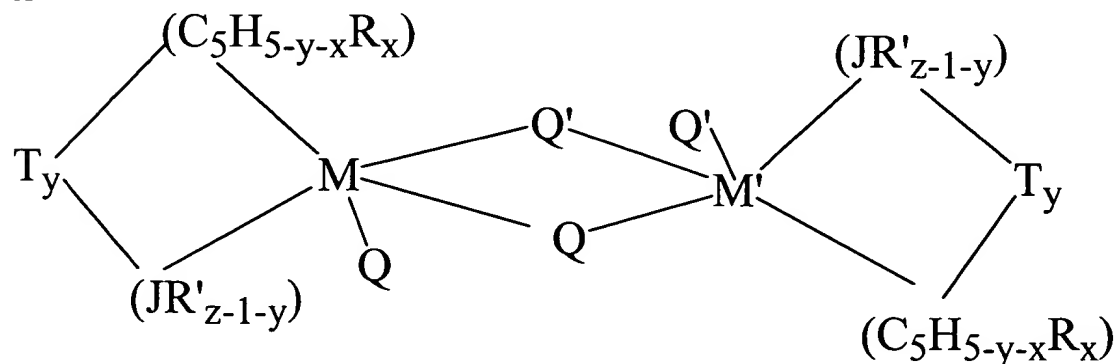
116. (New) The process of claim 105 wherein the alpha olefin is propylene.

117. (New) A process for the polymerization of one or more alpha olefins comprising conducting the polymerization in the presence of a catalyst system comprising:

(A) a Group IV B transition metal component of the formula:



or



wherein M Zr, Hf, or Ti;

M' has the same meaning as M;

(C₅H_{5-y-x}R_x) is a cyclopentadienyl ring which is substituted with from zero to four substituent groups R, x is 0, 1, 2, 3 or 4 denoting the degree of substitution, and each substituent group R is, independently, a radical selected from the group consisting of methyl, ethyl, propyl, butyl, octyl, benzyl, phenyl, trimethylgermyl, trimethylstannyl, triethylplumbyl, trifluoromethyl, trimethylsilyl, triethylsilyl, ethyldimehtylsilyl, methyldiethylsilyl, and triphenylgermyl, or (C₅H_{4-x}R_x) is a cyclopentadienyl ring in which two adjacent R substituents are joined forming a C₄-C₂₀ ring to give a saturated or unsaturated polycyclic cyclopentadienyl ligand;;

(JR'z-1-y) is a heteroatom ligand selected from the group consisting of *t*-butylamido, phenylamido, *p-n*-butylphenylamido, cyclohexylamido, perfluorophenylamido, *n*-butylamido, methylamido, ethylamido, *n*-propylamido, isopropylamido, benzylamido, *t*-butylphosphido, ethylphosphido, phenylphosphido, and cyclohexylphosphido, and z is 3; each Q selected is from the group consisting of hydride, methyl, ethyl, propyl, butyl, amyl, hexyl, heptyl, octyl, nonyl, decyl, cetyl, phenyl, chloro, bromo, fluoro, iodo, methoxy, ethoxy, propoxy, butoxy, phenoxy, methylphenoxy, dimethylamido, diethylolamido, methylethylamido, dibutylamido, dipropylamido, diphenylamido, diphenylphosphido, dicyclohexylphosphido, diethylphosphido, and dimethylphosphido;

Q' has the same meaning as Q;

y is 1;

T is selected from the group consisting of dialkyl, alkylaryl, or diaryl substituted silicon or germanium radicals, unsubstituted methylene and ethylene radicals;

L is a neutral Lewis base where w denotes the number 0 or 1; and

(B) an alumoxane,

118. (New) The process of claim 117 wherein T is selected from the group consisting of dimethylsilyl, diethylsilyl, di-*n*-propylsilyl, diisopropylsilyl, di-*n*-butylsilyl, di-*t*-butylsilyl, di-*n*-hexylsilyl, methylphenylsilyl, ethylmethylsilyl, diphenylsilyl, *n*-hexylmethylsilyl, cyclopentamethylenesilyl, cyclotetramethylenesilyl, cyclotrimethylenesilyl, dimethylgermyl, and diethylgermyl.

119. (New) The process of claim 117 wherein the process is solution process.

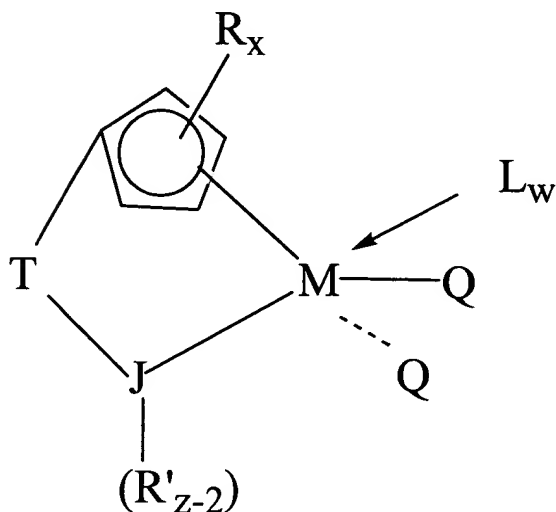
120. (New) The process of claim 117 wherein the Group IV B transition metal component is dimethylsilyl(tetramethylcyclopentadienyl)(tert-butylamido) M dichloride, where M is titanium, zirconium or hafnium.

121. (New) A process for polymerizing one or more olefins, diolefins or acetylenically unsaturated compounds comprising the steps of:

(i) contacting an olefin, diolefin or acetylenically unsaturated monomer at a temperature and pressure sufficient to polymerize such monomer with a catalyst system comprising:

(A) an alumoxane, and

(B) a Group IV-B transition metal component of the formula:



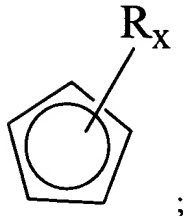
where M is Zr, Hf, or Ti;

R is a substituent group with X denoting the degree of substitution ($x = 0, 1, 2, 3, \text{ or } 4$) and each R is, independently, a radical selected from the group consisting of C_1 - C_{20} hydrocarbyl radicals, substituted C_1 - C_{20} hydrocarbyl radicals, substituted C_1 - C_{20} hydrocarbyl radicals wherein one or more hydrogen atoms is replaced by a halogen atom, an amido radical, a phosphido radical, an alkoxy radical, or any other radical containing

Lewis acidic or basic functionality, C_1 - C_{20} hydrocarbyl-substituted metalloid radicals wherein the metalloid is selected from the ~~group~~ Group IV A of the Periodic Table of Elements, and halogen radicals, amido radicals, phosphido radicals,; alkoxy radicals, alkylborido radicals or a radical containing Lewis acidic or basic functionality, or at least two adjacent R-groups are joined forming a C_4 - C_{20} ring to give a saturated or unsaturated polycyclic cyclopentadienyl ligand;

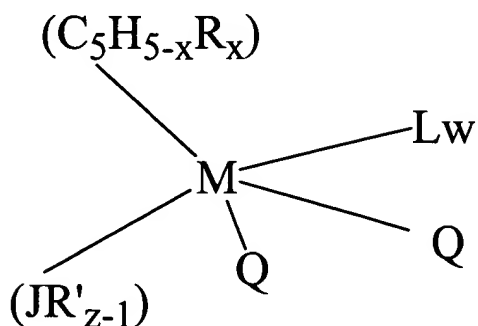
(JR'_{z-2}) is a heteroatom ligand in which J is an element with a coordination number of three from Group V-A or an element with a coordination number of two from Group VI-A, and R' is a radical selected from the group consisting of C_1 - C_{20} hydrocarbyl radicals, substituted C_1 - C_{20} hydrocarbyl radicals where one or more hydrogen atoms is replaced by a halogen radical, an amido radical, a phosphido radical, an alkoxy radical, or a radical containing Lewis acidic or basic functionality, and z is the coordination number of the element J;

each Q is, independently, a univalent anionic ligand group or two Q's together are a divalent anionic chelating ligand, provided that Q is different from

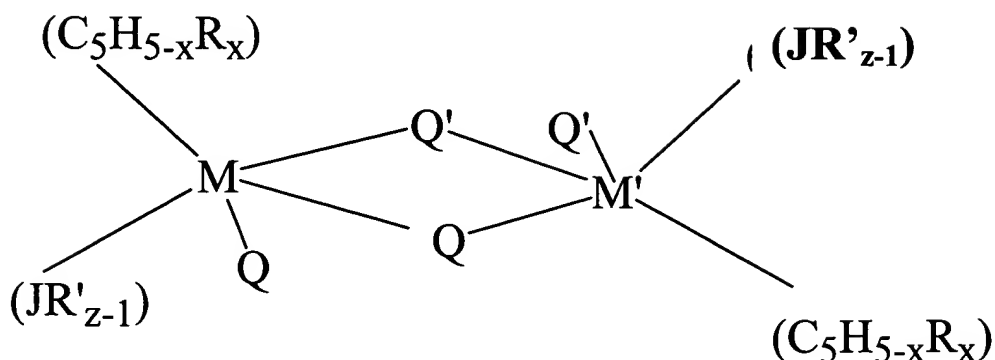


T is a covalent bridging group containing a Group IV-A or V-A elements; and L is a neutral Lewis base where w denotes a number from 0 to 3; and
(ii) recovering a polymer.

122. (New) A compound having the general formula:



or



wherein M is Zr, Hf or Ti;

$(C_5H_{5-x}R_x)$ is a cyclopentadienyl ring which is substituted with from zero to five substituent groups R, x is 0, 1, 2, 3, 4 or 5 denoting the degree of substitution, and each substituent group R is, independently, a radical selected from the group consisting of C_1 - C_{20} hydrocarbyl radicals, substituted C_1 - C_{20} hydrocarbyl radicals wherein one or more hydrogen atoms is replaced by a halogen atom, C_1 - C_{20} hydrocarbyl-substituted metalloid radicals wherein the metalloid is selected from the group IV A of the Periodic Table of Elements, and halogen radicals, or $(C_5H_{5-x}R_x)$ is a cyclopentadienyl ring in which two adjacent R groups are joined forming a C_4 - C_{20} ring to give a saturated or unsaturated polycyclic cyclopentadienyl ligand;

(JR'_{z-1}) is a heteroatom ligand in which J is an element with a coordination number of three from Group V-A or an element with a coordination number of two from Group VI-A of the Periodic Table of Elements, each R' is, independently, a radical selected from a group consisting of C_1 - C_{20} hydrocarbyl radicals, substituted C_1 - C_{20}

hydrocarbyl radicals where one or more hydrogen atoms is replaced by a halogen radical, and z is the coordination number of the element J;

each Q is, independently, selected from the group consisting of halogen, hydride and C₁-C₂₀ hydrocarbyl, provided that Q is different from (C₅H_{5-x}R_x);

L is a neutral Lewis base where "w" is a number greater than 0 and up to 3;

M' has the same meaning as M; and

Q' has the same meaning as Q.